

ABSTRACT OF THE DISCLOSURE

A process for producing a fluoroalkanol of high purity containing little evaporation residue, which can be industrially easily carried out with high selectivity, is provided. In the process, a radical initiator and $\text{CF}_2=\text{CFR}^3$ (formula 3) are continuously added to $\text{CHR}^1\text{R}^2-\text{OH}$ (Formula 2) to react them to form $\text{H}-(\text{CFR}^3\text{CF}_2)_n-\text{CR}^1\text{R}^2-\text{OH}$ (formula 1). In the formulae, n is an integer of from 1 to 4, each of R^1 and R^2 is a hydrogen atom or a C_{1-3} alkyl group, and R^3 is a fluorine atom or a C_{1-4} perfluoroalkyl group.